

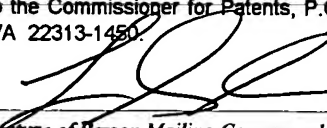


IFW

				Docket No. YOR920030598US1 (17231)	
TRANSMITTAL OF FORMAL DRAWINGS					
In Re Application Of: Stephen M. Gates, et al.					
Application No. 10/758,724	Filing Date 1/16/2004	Confirmation No. Unassigned	Examiner Unassigned	Customer No. 23389	Group Art Unit 1771
Invention: LOW K AND ULTRA LOW K SICOH DIELECTRIC FILMS AND METHODS TO FORM THE SAME					
Address to: Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450					
Transmitted herewith are: 7 sheets of formal drawing(s) for this application. <input checked="" type="checkbox"/> Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).					
 Signature			Dated: July 26, 2004		
Leslie S. Szivos, Ph.D. Registration No. 39,394			<div>I certify that this document and attached formal drawings are being deposited on 7/26/2004 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.</div> <div> Signature of Person Mailing Correspondence</div> <div>Leslie S. Szivos, Ph.D. Typed or Printed Name of Person Mailing Correspondence</div>		